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## APPLICATION DATA SHEET

<b>Title:</b>	<b>PROCESS FOR PRODUCING OPTICALLY ACTIVE 2-ALKYLCYSTEINE, DERIVATIVE THEREOF, AND PROCESSES FOR PRODUCTION</b>
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<b>Foreign Priority:</b>	This Application is the National Phase of International Application No. PCT/JP2004/017140 filed November 18, 2004, which designated the U.S. and was not published under PCT Article 21(2) in English, and this application claims, via the aforesaid International Application, the foreign priority benefit of and claims the priority from Japanese Application No. 2003-387965, filed November 18, 2003, Japanese Application No. 2004-173696, filed June 11, 2004, Japanese Application No. 2004-176623, June 15, 2004, Japanese Application No. 2004-184595, filed June 23, 2004, and Japanese Application No. 2004-184596, filed June 23, 2004, the complete disclosures of the aforesaid PCT application and the aforesaid Japanese applications are incorporated herein by reference.